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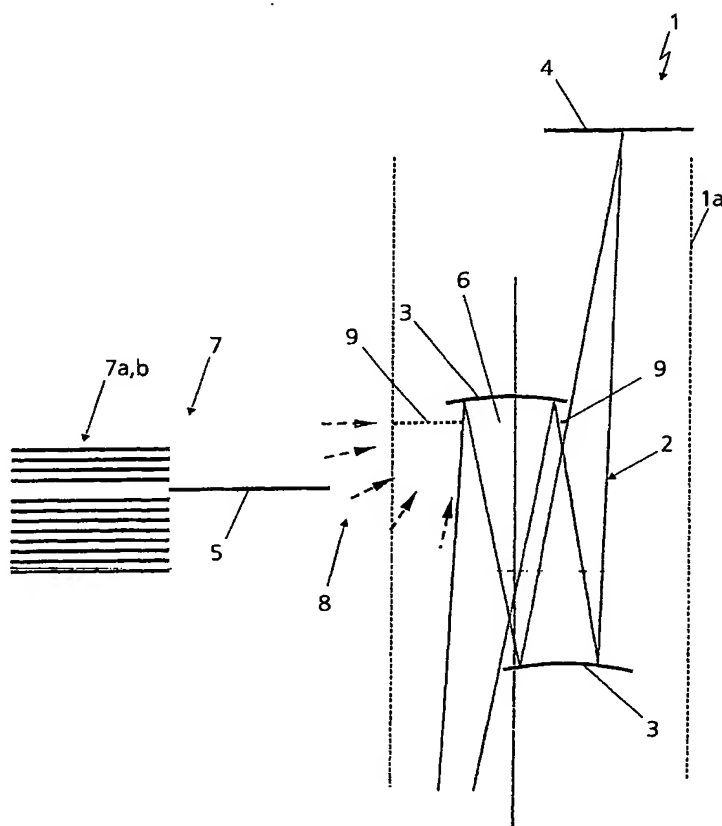
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(54) Title: DIAPHRAGM CHANGING DEVICE



(57) Abstract: The invention relates to an optical imaging device in particular an objective (1) for microlithography in the field of EUVL for producing semiconductor components, having a beam path (2), a plurality of optical elements (3) and a diaphragm device (7) with an adjustable diaphragm opening shape. The diaphragm device has a diaphragm store (7a, 7b) with a plurality of different diaphragm openings (6) with fixed shapes in each case, which can be introduced into the beam path (2).



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